

Visualization of Contamination with TXRF

Total Reflection X-ray Fluorescence Spectrometer

Advantage of TXRF









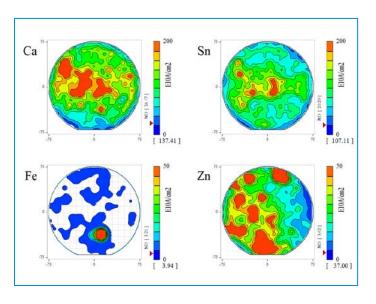


Quick and Easy Measurements

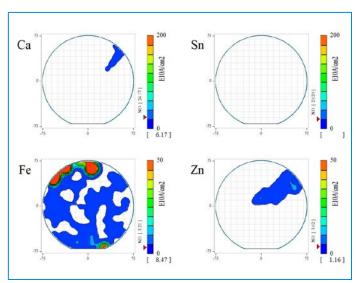
- · No sample pre-treatment required
- · Simple-to-maintain calibration
- · Even a novice can measure contamination thanks to user-friendly software

Sweeping-TXRF / ZEE-TXRF Applications

150 mm SiC Wafer - Process A



150 mm SiC Wafer - Process B



- ●TXRF provides entire wafer contamination mapping information
- Process A and B were run with different cleaning protocols by SiC wafer suppliers